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PLASMA THIN FILMS PREVENTING CHLORIDE IONS FROM INTERFERING WITH THE NERNSTIAN pH-RESPONSE OF PLATINUM ELECTRODE SURFACE

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ABSTRACT

The plasma-deposited polymer thin films at platinum surface were investigated as materials blocking access of chloride ions to the platinum surface and preventing their interference with the Nernstian response of platinum. In the presence of chloride ions, the pH response of a naked platinum was remarkably affected. By comparison of pH responses of coated and uncoated platinum-wire electrodes immersed in solutions with chloride ions, it was found that toluene and ethylbenzene plasma films could improve the pH response of platinum. The pH response of coated platinum electrodes may be explained by the ability of protons, by virtue of their small size, to move through the polymer matrix to the platinum surface.

INTRODUCTION

Recently, there has been interest in the use of chemically modified electrodes as potentiometric sensors^[1-3]. Platinum is worth notice as an electrode material for producing pH-sensing devices because it intrinsically shows the Nernstian potential response to pH of a solution^[4]. However, there is a problem that pH-response reactions at platinum surface is apt to be subject to interference of redox systems, especially chloride ions coexisting in the solution^[5]. One breakthrough to overcome the limitation and to develop ultramicro-pH-sensing devices^[6] composed of platinum involves interference-preventing polymer films at the platinum surface. In this study, the plasma-deposited thin films at platinum surface were investigated as materials blocking

access of chloride ions to its surface and preventing their interference with the Nernstian response of platinum. In the presence of chloride ions, the pH response of a naked platinum was remarkably affected. By comparison of pH responses of coated and uncoated platinum-wire electrodes immersed in solutions with chloride ions, it was found that toluene and ethylbenzene plasma films could improve the pH response of platinum. Those results and their significance in regard to sensor development will be discussed.

EXPERIMENTAL

Fabrication of plasma-film-coated platinum electrodes were carried out with an apparatus shown in Figure 1^[7]. A naked platinum wire (0.5-mm diam.x 5-cm length) was

fixed at the tip of a Pyrex glass rod and inserted into the apparatus to be put at a position of a, b or c. A Pyrex reactor tube (45mm diameter \times 80mm length) was connected to a vacuum system. a copper coil tubing was wound around the reactor tube. The coil was connected to a 13.56 MHz radiofrequency(rf) generator. After evacuation, a monomer vapor was introduced into the reactor from the reservoir vessel. The flow rate of the vapor(r_M) was estimated from the reduced weight of the reservoir and the elapsed time. The vapor pressure was $10\text{--}10^2$ Pa. The monomer plasma was generated by the inductively

coupled discharge. Plasma polymer grown in the gas-phase was deposited on the surface of the platinum wire. It was kept room temperature and not heated during the fabrication. The thickness of the so-obtained plasma film was estimated by a scanning electron microprobe. Used monomers were toluene (TOL), p-xylene (p-XY), ethyl-benzene(EB), styrene(SR), Methyl methacrylate (MMA) and so on, which were preliminary degased by freeze-pump-thaw method. Table 1 shows typical conditions for fabrication of plasma-film coated platinum electrodes used in this work.

Potential measurements were performed by a system shown in Figure 2 with using a TOA Model PM-18U dc microvoltammeter. The pH of a test solution was changed by adding every $10\text{--}\mu\text{l}$ 0.5 M sulfuric or 1 M acetic acid to 100-ml 0.01 M NaOH aq. and was determined with a Horiba Model D-13 pH meter. Obtained potentials were values vs. a saturated calomel electrode(sce). All measurements were carried out at room temperature(22°C)

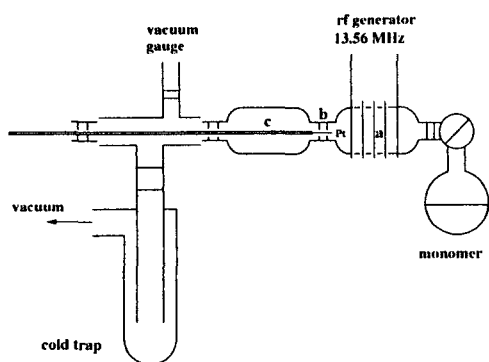


Fig. 1 Apparatus for fabrication of plasma-film-coated platinum-wire electrodes.

Table 1 Typical Fabrication conditions of Plasma Film-Coated Electrodes

Coated Pt	Monomer	Pa (W)	r_M^b (mmol min^{-1})	t^c (min)
TOL-	Toluene	50	0.111	1.0
EB-	Ethylbenzene	50	0.081	1.0
SR-	Styrene	50	0.104	1.0
p-XY-	p-Xylene	50	0.122	1.0
MMA-	Methylmethacrylate	50	0.136	1.0

^aPlasma power. ^bFlow rate of monomer. ^cCoating time.

RESULTS AND DISCUSSION

When an uncoated platinum electrode was immersed in a 100-ml 0.01 M NaOH aq. to which small volumes of 1.0M sulfuric acid was added step by step so to change pH over a range of 12-2, the potential-pH response obtained was linear over a pH range of 3 to 11, the slope was ca. -57 mV/pH as shown in Table 2 and Figure 3. This result indicates that the pH response of the electrode is approximately Nernstian. The response time for potential formation at this electrode was

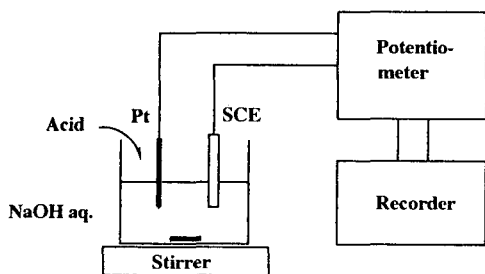


Fig. 2 System for potential measurements.

Table 2 Slopes of Typical pH response Curves

Acid	pH ^a	slope/mVpH ⁻¹
H ₂ SO ₄	3-11	-57
H ₃ PO ₄	3-12	-53
HNO ₃	2-12	-51
HCL	3-12	-42
Acetic acid	5-11	-56
	4-12 ^b	-50 ^b
	4-12 ^c	-46 ^c
	6-8 ^d	-59 ^d
Phthalate ^e	5-11	-54
Acetic anhydride	4-10	-48

^apH linear range. ^bAdded 0.5M urea. ^cAdded 1M urea. ^dAdded L-ascorbic acid. ^ePotassium hydrogen phthalate.

rather long, taking approximately 15min to reach stable values(i.e., less than 0.10mV/min change). After being coated with plasma films, the platinum electrodesexhibited slopes similar to that observed for the uncoated platinum electrode and the response time roughly equal to that for the uncoated electrode in the same solution mentioned above.

The presence of chloride ions evidently affected the potential-pH response of the electrode.

By comparison of the responses shown in Figure 3 for the coated and uncoated elec-

trodes in the presence of chloride ions, TOL and EB plasma films could improve well the pH response of platinum surface. it is evident that the values above pH 7 are roughly the same for both surfaces, while a significant difference between the two responses exists below pH 7. For the other platinum surfaces, a similar but less pronounced effect was noted, except that the curves for the coated and uncoated electrodes coincided more closely at low pH than at high pH.

These studies indicate that, although a rather stable plasma polymer film is present on the platinum electrode surface, the observed pH response of the system appears to be due principally to the platinum surface.

The response observed at platinum most probably involves an oxide layer on the platinum surface. The curvature in pH response observed at the coated electrodes is evidently due to the presence of the polymer films. This effect may involve some small pH response of the films themselves or may reflect some pH-dependent property of the films(e.g., molecular conformation).

It is interesting to speculate that the presence of the polymer coating may actually improve the performance(selectivity)of these electrodes by blocking access of larger redox systems to the electrode surface, whereas the response to protons through the polymer film could still occur.

In any event, these results indicate that the development of potentiometric sensors must take into account the properties of the substrate material employed in their construction.

CONCLUSION

In the presence of chloride ions, the pH response of a naked electrode was remarkably affected. By comparison of the responses for the coated and uncoated electrodes in the presence of chloride ions, it was found that TOL and EB plasma films could improve the potential-pH response of platinum surface. The response of coated platinum electrodes to pH may be explained by the ability of protons, by virtue of their small size, to move through the polymer matrix to the platinum surface. Since the response observed at platinum most probably involves an oxide layer on the platinum surface, it is interesting to speculate that the presence of the polymer coating may actually improve the performance of these electrodes by blocking access of chloride ions to the electrode surface, whereas the response to protons through the polymer film could still occur.

The curvature in pH response observed at the coated electrodes is evidently due to the presence of the polymer films. This effect

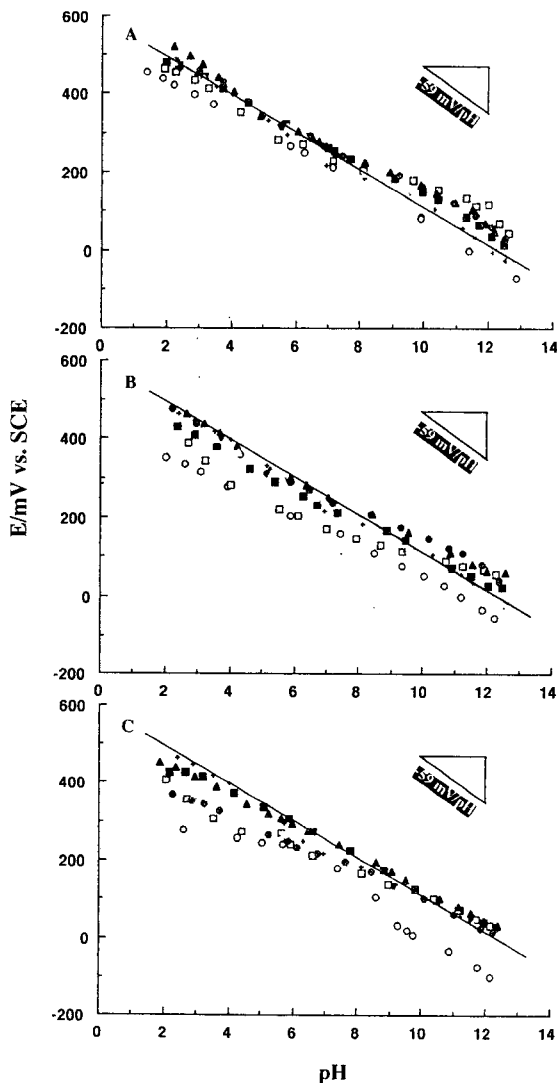


Fig. 3 Effect of plasma thin films on chloride ions interfering with the Nernstian pH-response of platinum surface :

Three Figures show pH responses of electrodes of uncoated Pt(○), TOL-coated Pt(■), p-XY-coated Pt(□), EB-coated Pt(▲), SR-coated Pt(△), and MMA-coated Pt(●) in test solutions including chloride ions as follows :

- A, 0.01M-NaOH aq. to which 1M-HCL was added;
- B, 0.01M-NaOH aq. with 4% NaCl to which 0.5M-H₂SO₄ was added;
- C, 0.01M-NaOH aq. with 16% NaCl to which 0.5M-H₂SO₄ was added.

symbolic+ shows the pH-response of an uncoated electrode immersed in the solution including no chloride ion: 0.01M-NaOH aq. to which 0.5M-H₂SO₄ was added, and solid lines show the averaged Nernstian pH-response.

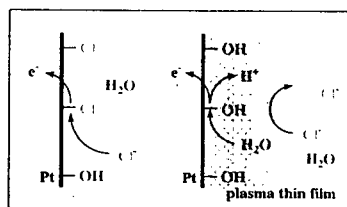
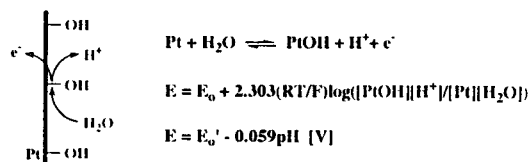


Fig. 4 Scheme of Nernstian response and interference of Cl₂.

may involve some small pH response of the films themselves or may reflect some pH-dependent property of the films (e.g., molecular conformation). In any event, these results indicate that the development of potentiometric sensors must take into account the properties of the substrate material employed in their construction.

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